Accepted Manuscript

Phosphorus removal from upgraded metallurgical-grade silicon by vacuum directional solidification

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PII: S0042-207X(17)30468-2

DOI: 10.1016/j.vacuum.2017.08.037

Reference: VAC 7563

To appear in: Vacuum

Received Date: 14 August 2017

Accepted Date: 30 August 2017

Please cite this article as: Zhang C, Wei K, Zheng D, Ma W, Dai Y, Phosphorus removal from upgraded metallurgical-grade silicon by vacuum directional solidification, *Vacuum* (2017), doi: 10.1016/ j.vacuum.2017.08.037.

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ACCEPTED MANUSCRIPT

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14	Abstract:
15	The removal of phosphorus impurities is among the most important problems in
16	the purification of upgraded metallurgical-grade silicon (UMG-Si) used in the
17	preparation of solar-grade silicon (SOG-Si). Vacuum refining is considered relatively
18	effective for removing phosphorus from molten silicon. Based on the saturated vapor
19	pressure of phosphorus calculated, the removal of phosphorus from UMG-Si at 1823K
20	was performed via an industrial-scale vacuum directional solidification (VDS) furnace
21	in this paper. Amathematical model for phosphorus removal during VDS was proposed

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